



(12) **United States Design Patent**
Tauchi et al.

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(54) **LOWER CHAMBER FOR A PLASMA PROCESSING APPARATUS**

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(**) Term: **15 Years**

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(21) Appl. No.: **29/544,071**

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(30) **Foreign Application Priority Data**

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(51) **LOC (10) Cl.** **13-03**

(52) **U.S. Cl.**
USPC **D13/182**

(58) **Field of Classification Search**
USPC D13/118, 123, 154, 156, 173, 177, 182,
D13/184, 199; D8/70, 90, 396;
D15/126, 138, 139
CPC B24B 5/00; B24B 7/00; B24B 7/22; B24B
37/04; B24B 37/28; B24B 37/32; B24B
1/00; B24B 29/00; C30B 23/02; H01L
21/304; H01L 21/67; H01L 21/68; H01L
21/00; H01L 21/32; Y10S 41/139; C23C
16/00; C23C 16/45; C25D 17/00; H01R
3/00

See application file for complete search history.

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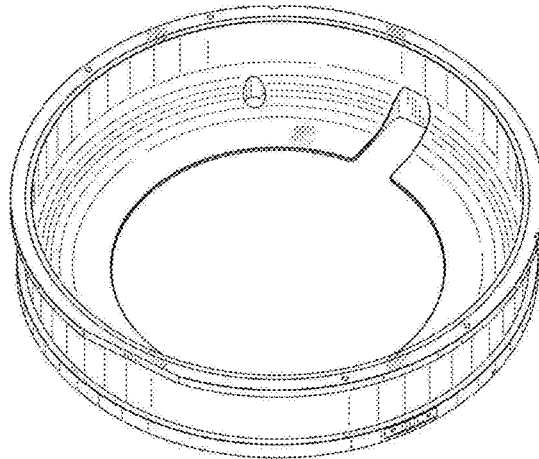
(57) **CLAIM**

The ornamental design for a lower chamber for a plasma processing apparatus, as shown and described.

DESCRIPTION

FIG. 1 is a front, top and right side perspective view of a lower chamber for a plasma processing apparatus according to the design;
FIG. 2 is a front elevational view thereof;
FIG. 3 is a rear elevational view thereof;
FIG. 4 is a left side elevational view thereof;
FIG. 5 is a right side elevational view thereof;
FIG. 6 is a top plan view thereof;
FIG. 7 is a bottom plan view thereof;
FIG. 8 is a cross-sectional view taken along line 8-8 of FIG. 6;
FIG. 9 is a cross-sectional view taken along line 9-9 of FIG. 6; and,
FIG. 10 is a partially enlarged view taken along line 10-10 of FIG. 8.

1 Claim, 6 Drawing Sheets



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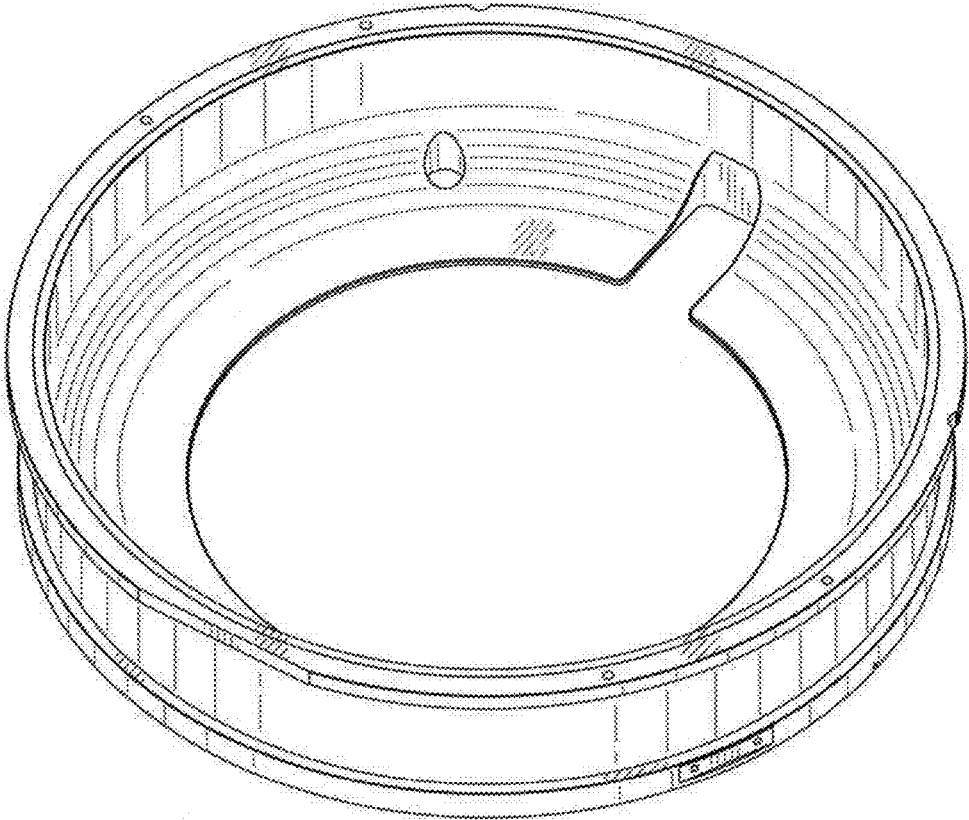


FIG. 1

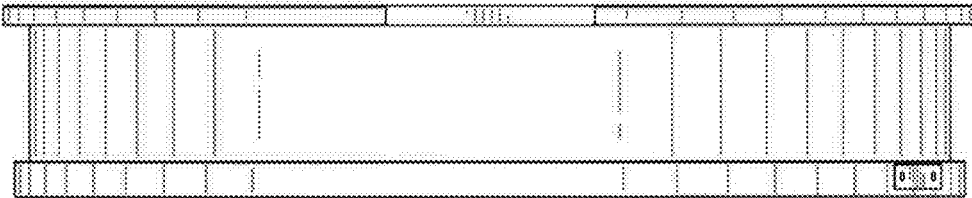


FIG. 2

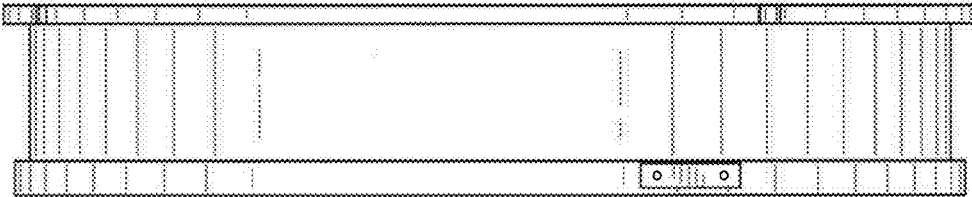


FIG. 3

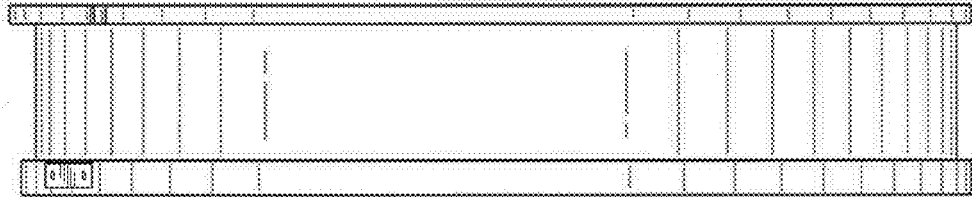


FIG. 4



FIG. 5

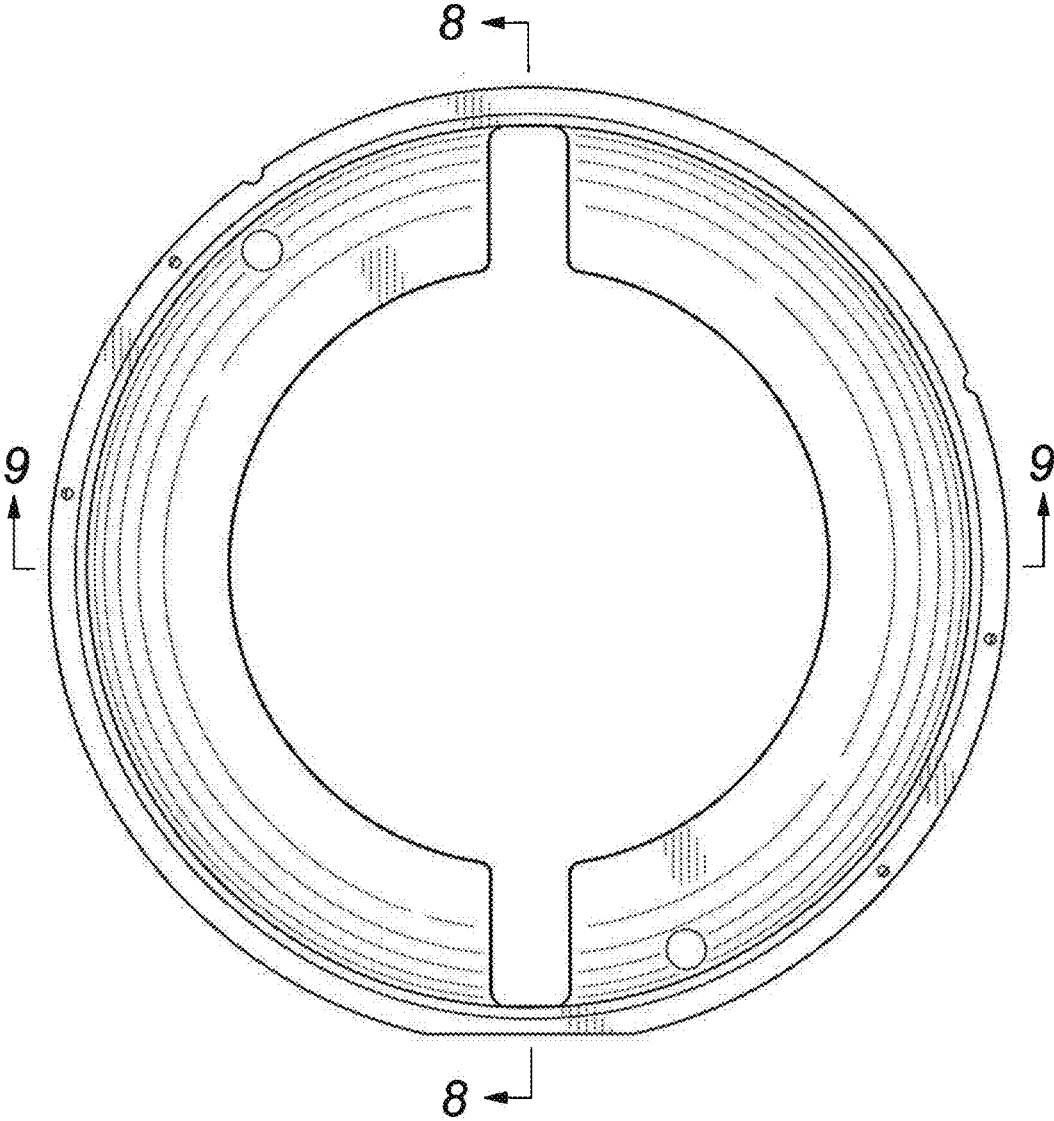


FIG. 6

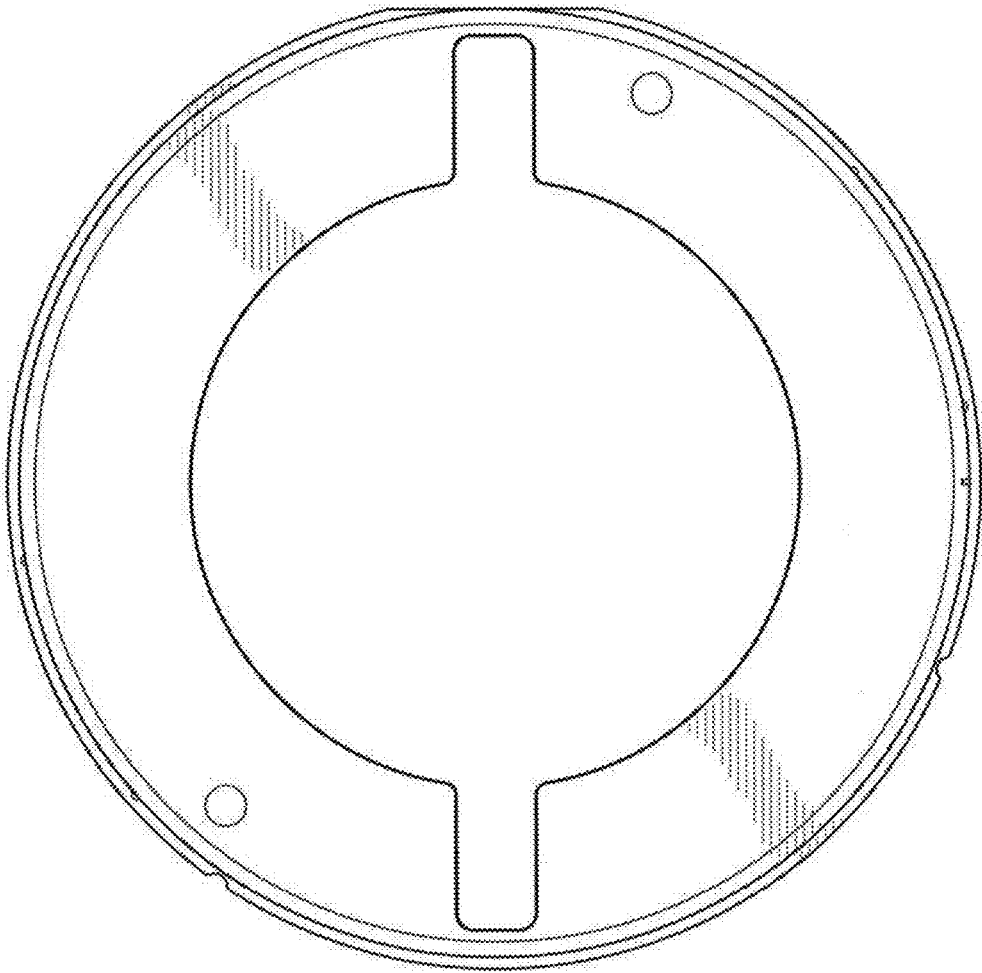


FIG. 7

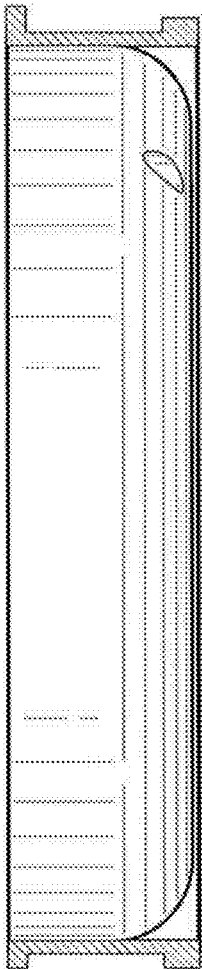


FIG. 8

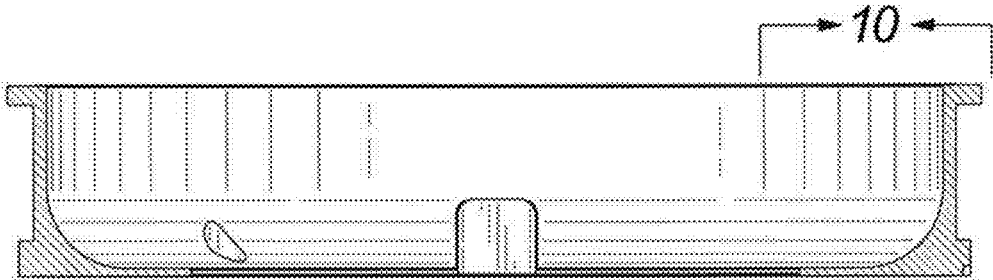


FIG. 9

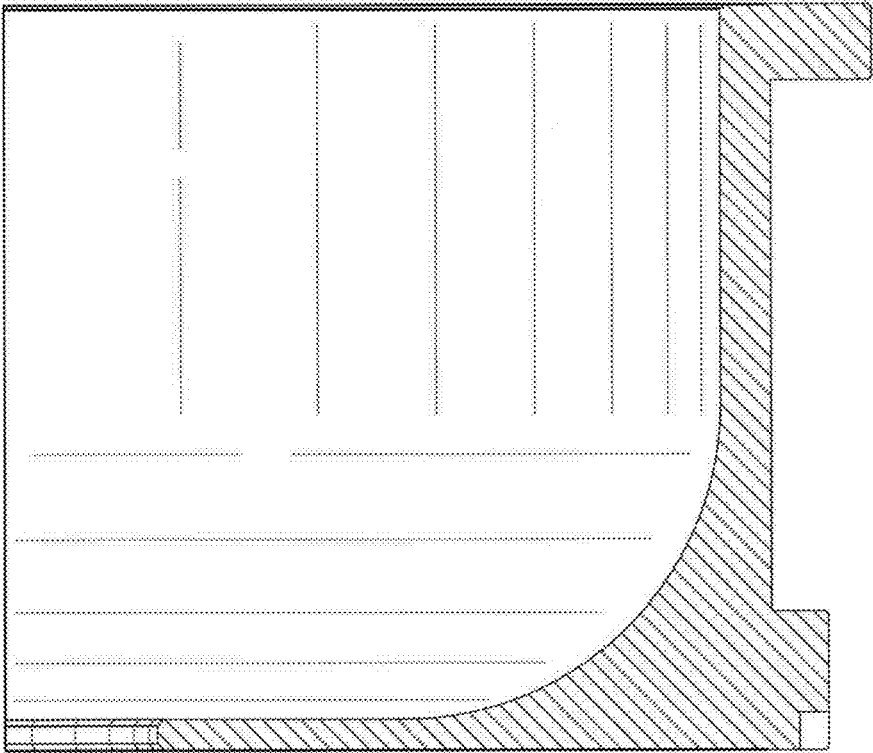


FIG. 10